



Quantum mechanical predictions of defect properties for realistic device simulations

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Electronic

Structure

Tight

Binding

Empirical

Potentials

Speed

Quantum

Monte-Carlo

Introduction: Defects in Silicon Devices

- Ion implantation-induced interstitials precipitate extended defects
- Extended defects facilitate the broadening of doping profiles, which limits device size
- Radiation damage in space technology
- Experiments indicate the need for accurate defect simulations [2]

Back end Gate Drain Front end B-doped P-doped Si



"Extended {311} Defect [1]"

Transition state methods identify defect geometries

Accuracy

Molecular dynamics and dimer method

• Provides candidate structures for defects and saddle points [6]

Nudged Elastic Band Method

• Identifies defects and energy barriers

Transition State Theory

• Calculates transition rates

Hohenberg-Kohn Theorem (1964)

The ground state energy given by its electron density n(r).

Electronic structure methods refine geometries and pathways

- Nobel prize in chemistry 1998 (Kohn and Pople)
- Most widely used "first principles" method

Checking the accuracy of the unknown density functional

• Climbing "Jacob's ladder" to heaven of chemical accuracy [3]

Methods: A Multiscale Approach

Jacob's Ladder of DFT

Exchange Correlation Potentials

- Comparison to experiment or quantum chemistry
- Benchmark calculations by quantum Monte Carlo

QMC determines accuracy of atomistic parameters

- Stochastic solution of the many-body Schrodinger equation
- Explicitly includes electron-electron correlation and exchange via many-body wavefunctions
- Variational Monte Carlo: Optimizes the wavefunction by energy minimization [4].
- Diffusion Monte Carlo: Solves imaginary time Schrodinger equation and projects out the ground state [5].

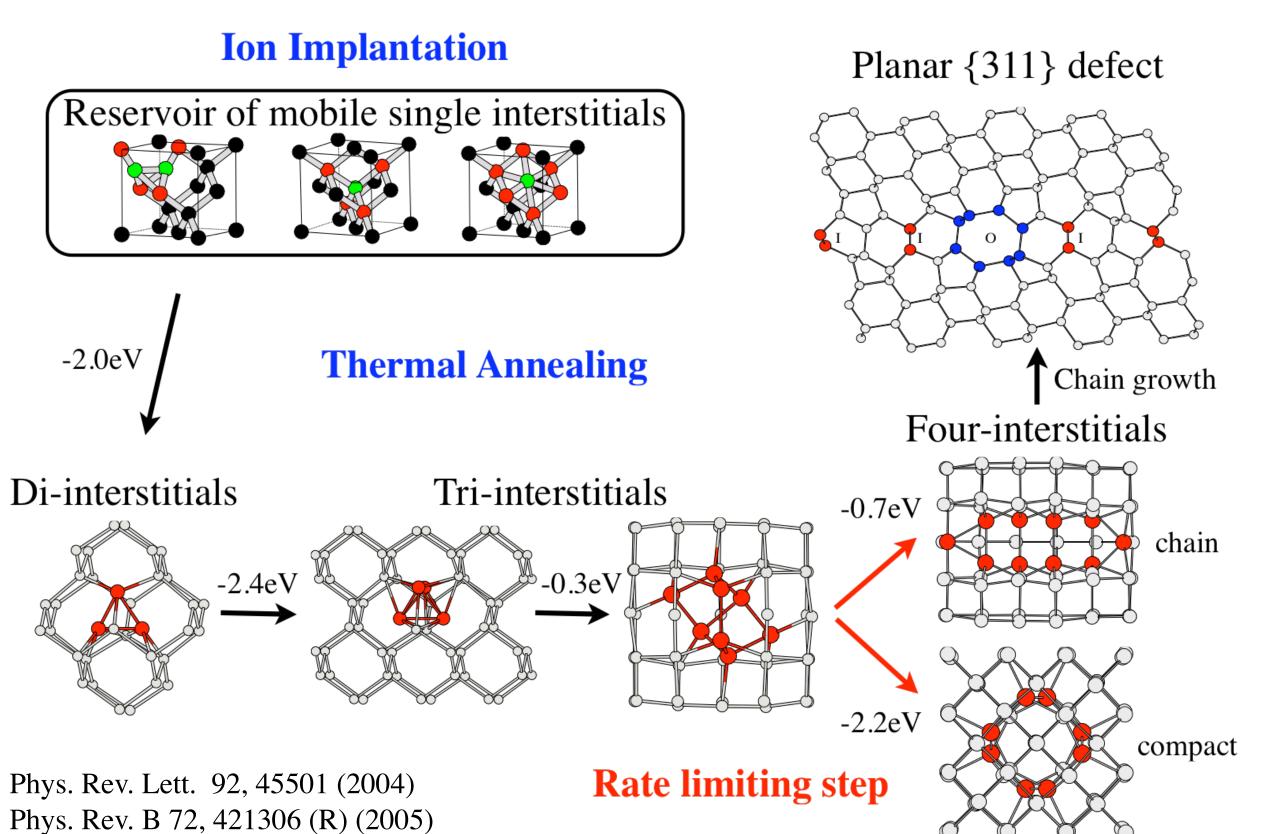
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Acknowledgements

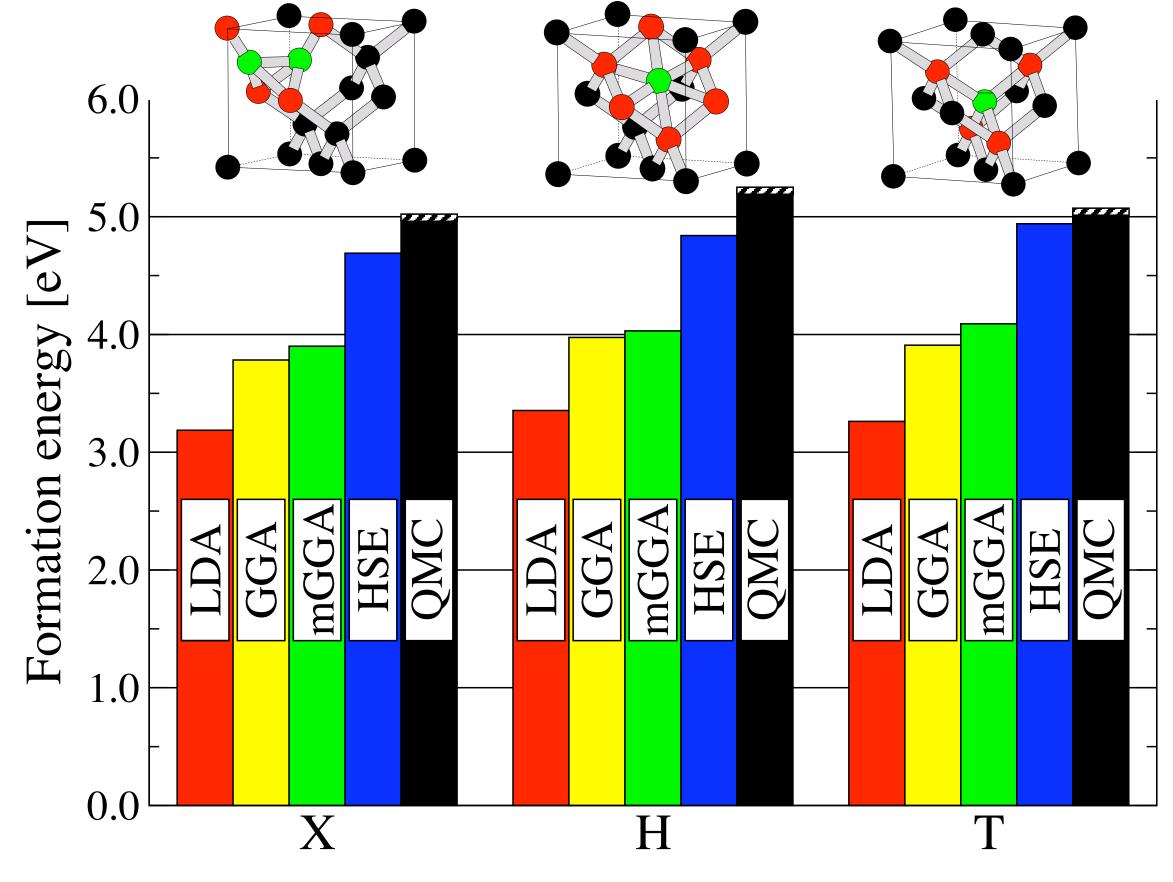
Support provided by DOE, NSF, and Sandia National Laboratory. We thank J. L. Martins for providing his density-functional code, and D. Alfe, C. Filippi, R. Needs, P. Kent, S. Goedecker for helpful discussions Computational Facilities: OSC, NERSC, NCSA, Cornell Theory Center.

Defect Evolution: From Point to Extended



Mobile single interstitials first precipitate small compact defects and then larger, extended clusters. The compact four-interstitial can frustrate the growth of extended structures.

Single Interstitial Formation Energies:



Climbing "Jacob's ladder" of density functionals improves the accuracy for defect formation energies. The highest rung-hybrids-agree with QMC.

Interstitial Diffusion Barriers

Heaven of

chemical accuracy

GGA

Experiment

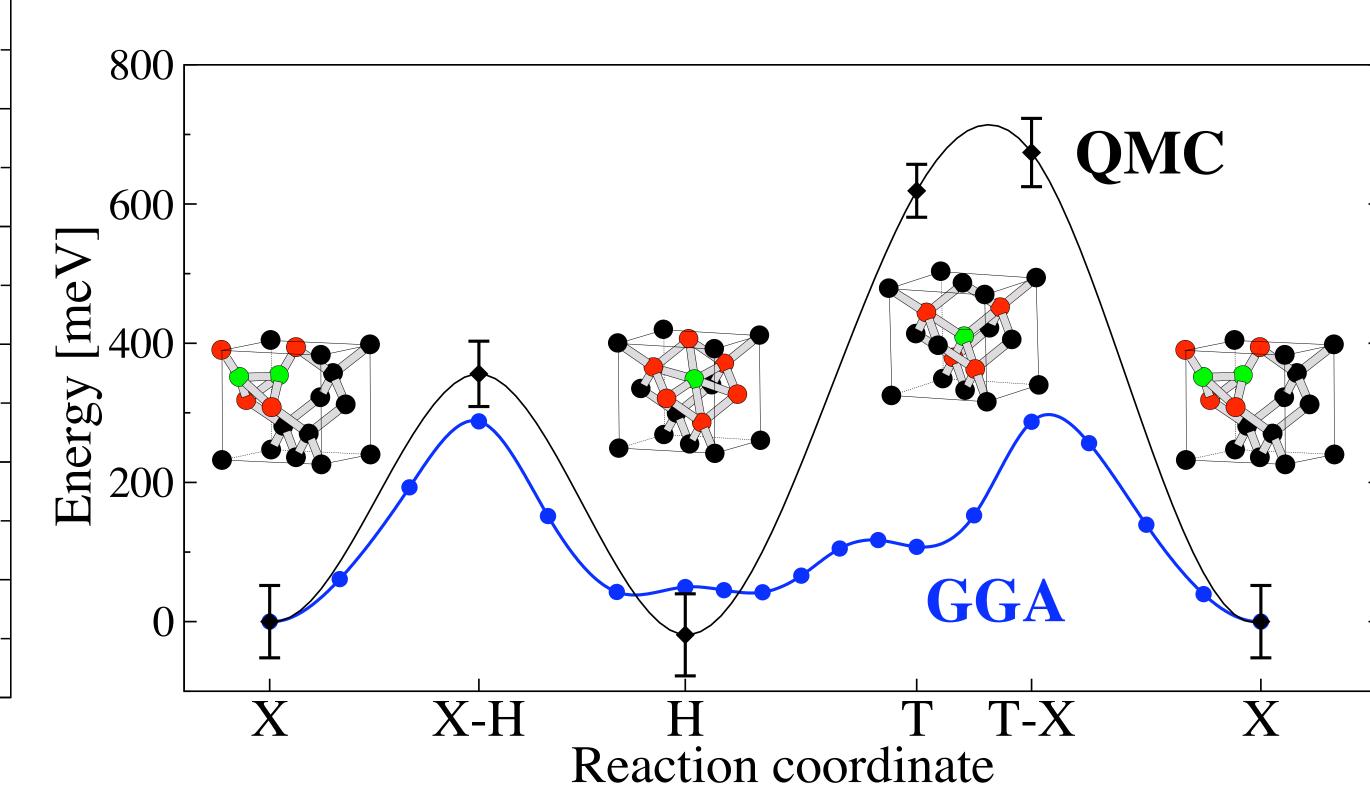
Monte Carlo

exact exchange

laplacian of density

density gradient

local density



Lowest energy barrier from X to H defect is similar in QMC and DFT. The T defect and its barrier are higher in QMC.